Quantum Dot Laser Epitaxial Wafer / Foundry Service

1300nm Quantum Dot Laser for Silicon Photonics

- High-temperature operation for densely integrated optoelectronics
- High optical feedback tolerance for removing isolator from your system
- Full-service foundry of customized epitaxial wafer and wafer process from development to mass production



Application examples

- Silicon photonics
 - Intra-data center comm.
 - High performance computer
 - LiDAR (FMCW, ToF)
 - Intra-vehicle comm.
 - Mobile infrastructure
- Underground resources exploration (175-200°C)



Quantum dots

Quantum dot laser, gain chip

- Operation up to 200°C, enabling densely packed laser array
- High optical feedback-tolerance (<-130dB/Hz. Cf. QW<-120dB/Hz at -30dB)

MAL PELL

- Highly reliable at high temperatures (Est. lifetime > 300Khrs at 85°C)
- Customized wide-band gain spectrum upon request

Epitaxial wafer / Foundry service

💥 QD LASER

- Epitaxial wafer (w/, w/o grating), wafer process, facet coating available
 - Wafer for wafer bonding, FP/DFB laser, gain chip
 - Multi-channel laser array, laser for flip-chip bonding
- Customized epitaxial wafer and chip design
- Full-service foundry from development to mass production



https://www.qdlaser.com info@qdlaser.com



Product Lineup*

Wavelength	Туре	Form	Output Power (mW)
1300nm	FP	Chip, TO-CAN	>10
1300nm	DFB	Chip, TO-CAN	>10
1240nm	DFB	Chip, TO-CAN	>10
1120-1310nm	Epitaxial wafer	Wafer	n/a

Foundry Service*

Menu	Description	
Epitaxial Wafer	Epitaxy on 3inch GaAs substrate	
Epitaxial Wafer with Grating	1 st epi, grating formation, regrowth	
Wafer Process	CAD, photo mask, wafer process	
Chip Fabrication	Bar cleaving, facet coating, chipping	



*Please contact us for other wavelengths and options





https://www.qdlaser.com info@qdlaser.com